

Detail of DST-Rajasthan R&D Project

Title : Growth and characterization of Zn-based compound semiconductor thin films as buffer layer for solar cell applications.

Agency : Department of Science and Technology (DST), Rajasthan

Scheme : Research & Development (R&D)

Duration : April 1, 2018- March 31, 2021 (Three years)

Amount sanctioned : Rs. 7,00,000/-

Equipments : N.A.

Manpower : Ms. Divya Agrawal, Junior Research Fellow (joined on July 19, 2018)

Achievements : Project under progress

Publication : Nil

Last updated: July 23, 2018